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Direct observation of a gap opening in topological interface states of MnSe/Bi$_2$Se$_3$ heterostructure

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High-quality MnSe(111) film was bilayer-by-bilayer grown epitaxially onto the Bi$_2$Se$_3$(111) surface using molecular beam epitaxy. Reversal scenario with quintuple layer-by-layer growth of Bi$_2$Se$_3$ onto the MnSe film was also realized. Angle-resolved photoemission spectroscopy measurements of Bi$_2$Se$_3$ capped with two bi-layers of MnSe revealed that an energy gap of about 90 meV appears at the Dirac point of the original Bi$_2$Se$_3$ surface, possibly due to breaking the time-reversal symmetry on the Bi$_2$Se$_3$ surface by magnetic proximity effect from MnSe. © 2015 AIP Publishing LLC.
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Unique quantum mechanical properties of topological insulators (TI) as well as their name originate from nontrivial topology in Hilbert space spanned by wave functions of their electronic states. At the interface of insulators with trivial and nontrivial topology, the energy gap has to be closed for the sake of changing topology. As a result, gapless surface electronic states with Dirac-cone dispersion are formed. In the time-reversal invariant systems, the nontrivial topology of TIs is protected by time-reversal symmetry (TRS). At the same time, robustness of the topological surface states against non-magnetic perturbation and disorder is also associated with TRS.

On the other hand, violation of TRS in such systems will lead to another set of fascinating effects. Exchange field would lift the Kramers degeneracy at the Dirac point and introduce a mass into the Dirac equation, that is, the critical point for observation of quantum anomalous Hall effect (QAHE) and topological magnetoelectric effect (TME). There are two common ways to introduce ferromagnetic order into the system for violating TRS: doping by magnetic atoms during the crystal growth and magnetic proximity effect at the surface. Both of them have their strengths and weaknesses.

Doping is a convenient method and shows some remarkable results. For the Te-based TIs, ferromagnetic ordering was observed, as well as QAHE. However, these samples did not show a Zeeman gap at the topological surface states in the angle-resolved photoemission spectra (ARPES). In contrast, a magnetically doped Bi$_2$Se$_3$ showed a gap up to several tens meV, but very small or even no magnetic hysteresis in the transport and magnetic measurements. In addition, the doping is not very useful for observing TME, because in order to reach the goal, the TRS should be broken on the surface, but not in the bulk. Proximity-induced magnetic field on the TIs can be obtained by depositing ferromagnetic metals on the surface of TIs, albeit with a variable success. Furthermore, such a continuous metallic layer will hide signal from TI. Instead, several ferromagnetic insulators (FMI) such as EuS and MnSe were proposed as promising candidates for this purpose. Experimentally, the proximity-induced interfacial magnetization of Bi$_2$Se$_3$ was realized in the systems with EuS, Y$_3$Fe$_5$O$_{12}$, and BaFe$_{12}$O$_{19}$ (Ref. 16) used as magnetic insulators.

In the present paper, we report experimental results on the growth of the antiferromagnetic MnSe film (ferromagnetic ordering in each (111) atomic plane with alternating spin directions from plane to plane) on the Bi$_2$Se$_3$(111) and effect of such a coating on the topological surface states.

Thin-film growth using molecular beam epitaxy was conducted in a ultrahigh vacuum (UHV) chamber with a base pressure less than $5.0 \times 10^{-10}$ Torr, equipped with reflection-high-energy electron diffraction (RHEED) facility. We used n-type Si(111) wafers (40–70 Ω cm) as substrates. Atomically clean Si(111)$\times7$ surface was prepared in situ by flashing to $1280^\circ$C after the wafer was first outgassed at $600^\circ$C for 6 h. Manganese, bismuth and selenium were evaporated from effusion cells with integrated shutters. The prepared samples were transferred into another UHV chamber, equipped with scanning tunneling microscopy (STM) and ARPES facilities, using evacuated transfer unit. ARPES measurements were conducted using VG Scienta R3000 electron analyzer and high-flux He discharge lamp ($h\nu=21.2$ eV).

To prepare Bi$_2$Se$_3$, we used combination of the two well-known approaches. First, we obtained a surface without dangling bonds by preparing Si(111)$\beta = \sqrt{3} \times \sqrt{3}$–Bi (Ref. 20) reconstruction. Then, three quintuple layers (QL) of Bi$_2$Se$_3$ were grown at relatively low sample temperature of about $150^\circ$C to avoid reaction with the silicon substrate. At
this temperature, the film growth proceeds in QL-by-QL fashion in which RHEED specular-spot intensity oscillation was observed (Fig. 1(a)). To improve the crystal quality of the film, the other layers were grown at a higher temperature of about 240°C at which the film grew in step-flow mode. To reduce the amount of Se vacancies, the Bi-to-Se flux ratio was chosen close to 1:14 (Ref. 19) with the growth rate of about 0.3 QL/min.

MnSe has a rocksalt crystal structure with lattice constant in the (111) plane \(a = 3.86\) Å (Ref. 21) which matches with that of Si(111) and is close to Bi\(_2\)Se\(_3\) one. Direct overgrowth of MnSe on the Si substrate is not possible due to the formation of silicide. But, on the Bi\(_2\)Se\(_3\) surface, the MnSe was easily grown epitaxially. We used the same Se-rich condition as for the MnSe growth, with the Mn rate being about 0.8 ML/min (monolayer, \(7.8 \times 10^{-14}\) cm\(^2\)), at the sample temperature 240°C. Under these conditions, RHEED specular-spot intensity oscillations corresponding to the bi-layer (BL)-by-BL growth, decreased rapidly (Fig. 1(b)), which indicated a transition to the step flow-growth mode. Reversal scenario of Bi\(_2\)Se\(_3\) growth on top of the MnSe film was also realized using the same growth conditions (Fig. 1(c)), which opens a possibility of studying the interlayer exchange coupling in FMI/TI/FMI structure.\(^{22}\)

The ratio of distances between streaks in the RHEED patterns (Fig. 1) for different top layers, Bi\(_2\)Se\(_3\) ((a) and (c)) and MnSe (b) coincides well with the reciprocal ratio of lattice constants (Bi\(_2\)Se\(_3\) –4.14 Å and MnSe –3.86 Å). The RHEED patterns indicated high crystal quality and absence of any extrinsic spots. STM observations also confirmed high quality of the grown Bi\(_2\)Se\(_3\) (Fig. 2(a)) and MnSe (Fig. 2(b)) films. The STM image, Fig. 2(d), of Bi\(_2\)Se\(_3\) a half of which is covered by the bi-layer of MnSe was obtained by stopping the MnSe growth near the first minimum in the RHEED specular spot intensity plot in Fig. 1(b), showing that we obtained exactly the single-BL islands of MnSe. In the line profile of STM image in Fig. 2(d), one can see steps with two different heights of \(\approx 0.9\) nm and \(\approx 0.3\) nm, which correspond to the Bi\(_2\)Se\(_3\) quintuple layer and MnSe bi-layer with 1 nm and 0.315 nm thick, respectively. For clarity, the crystal structures are given in Fig. 2(c).

Finally, we investigated the electronic structure of the grown films. Limited by electron escape depth,\(^{23}\) we could only probe the buried topological interface states for the samples with small MnSe thicknesses of below 3 BL. Figure 3 shows ARPES band dispersion of the pristine Bi\(_2\)Se\(_3\) (a) and that capped by 2 BL MnSe (b). Since possible slight tilt of sample with respect to the horizontal slit in the energy analyzer, could vary a gap size, if any, we conducted ARPES measurements at \(\Gamma \) point, where we were sure that the spectrum cut crossed the center of Brillouin zone. In the band dispersion of pristine Bi\(_2\)Se\(_3\) (Fig. 3(a)), one can see the bulk bands and the topological surface states (TSS) with Dirac point at \(\approx 0.34\) eV. In the energy distribution curve (EDC) at \(\Gamma \) (Fig. 3(a), bottom), there is a single-peak structure at the Dirac point. For fitting the spectrum, we used two Lorentzian peaks to take into account the bulk valence band

![FIG. 1. Intensity oscillations of the RHEED specular spot during the initial stages of growth (left column) and corresponding RHEED patterns of the grown films (right column) of (a) 12 QL of Bi\(_2\)Se\(_3\) film on Si(111), (b) 10 BL of MnSe/Bi\(_2\)Se\(_3\)/Si(111), and (c) 14 QL of Bi\(_2\)Se\(_3\)/MnSe/Bi\(_2\)Se\(_3\)/Si(111), respectively. The distance between streaks is marked by red arrows. Blue dotted lines are drawn through the centers of the Bi\(_2\)Se\(_3\) RHEED streaks.](attachment:fig1.png)

![FIG. 2. STM images (200 \times 200 nm\(^2\), insets are 2 \times 2 nm\(^2\)) of (a) 16 QL of Bi\(_2\)Se\(_3\) film on Si(111) and (b) 2 BL of MnSe film grown on the Bi\(_2\)Se\(_3\) film. (c) The crystal structures of MnSe and Bi\(_2\)Se\(_3\). The dashed red frames mark the corresponding units of MnSe bi-layer and Bi\(_2\)Se\(_3\) quintuple layer. (d) STM image (180 \times 90 nm\(^2\)) of about a half of the bi-layer of MnSe grown on the Bi\(_2\)Se\(_3\) film, and the corresponding STI height profile along a white line in the STM image. The line profile was acquired from the raw data, while the STM images were filtered using fast Fourier transform.](attachment:fig2.png)
and Dirac cone. In the band dispersion of Bi$_2$Se$_3$ with 2 BL of MnSe (Fig. 3(b)), one can clearly see a drop in intensity at the Dirac point. In the EDC, this corresponds to a double-peak structure. According to the fitting results, the gap size is about 90 meV—higher than those in the cases of Fe-doped and Mn-doped Bi$_2$Se$_3$ ($\leq$50 meV). Since we could not see clearly the gap opening at a 1 BL-MnSe covered Bi$_2$Se$_3$ (not shown here), the 2 BL of MnSe is believed to be a critical thickness for opening the gap.

However, other possible reasons for the loss of the spectral weight at the Dirac point cannot be excluded. We can rule out the top-layer-relaxation caused by the mechanical cleavage for our MBE grown samples. Then, according to Bergman and Refael gap-like features can appear in case when continuum of bulk states overlaps with topological surface states. But in our case the bottom of conduction band moves to even higher binding energies. So, if the bulk band gap does not change, the top of the valence band would move even further from the Dirac point. Bulk band gap could vary due to possible manganese doping into the Bi$_2$Se$_3$, but according to Xu et al. such intermixing would lead to a different bulk conduction band behavior. Anyway, we cannot exclude appearance of the impurities and defects states in Bi$_2$Se$_3$ after MnSe overgrowth, which might lead to broadening of the electronic states along momentum and energy axes and initiate the twin peak structure near the Dirac point.

Direct verification on the origin of the gap opening reported here could be gained with spin-resolved ARPES and anomalous Hall effect measurements.

In conclusion, epitaxial growth of a MnSe thin film on the Bi$_2$Se$_3$ (111) as well as the reversal growth of Bi$_2$Se$_3$ on MnSe were realized. It was shown that the films grew epitaxially with high crystallinity and sharp interfaces. Photoemission results unambiguously demonstrated that topological surface states at the interface of such a heterostructure remain, with developing an energy gap of about 90 meV at the Dirac point, possibly due to the broken time-reversal symmetry at the interface. Taking into account the high quality and straightforward fabrication procedures, the grown heterostructures are believed to be conducive and promising candidates for observing quantum phenomena like topological magnetoelectric effect and quantum anomalous Hall effect.

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